

# AXIS

*Maximum throughput, uncompromised process control*

AXIS embodies beam stability and precise process control: two essential requirements for industrial micromachining where consistency, reproducibility, and uptime are critical. Delivering advanced functionalities and process flexibility while pushing performance further with significantly higher average power, AXIS offers up to **120 W** and enables a new level of throughput for applications where our lasers' versatility has already proven its value, simply by increasing scan speed and repetition rate.

Its amplifier cooling technology and temperature stability ensure reliable **24/7 industrial operation**, with a high level of EMC immunity and radiation robustness. AXIS is particularly well-suited for high-throughput industrial applications, including multibeam processing and advanced display manufacturing, with UV output available **up to 45 W** and operation at repetition rates **up to 1.2 MHz**, as well as DUV-compatible configurations.

For customers who have developed processes based on the versatility of Satsuma X, AXIS represents the next step forward: the same process toolbox, now fueled by higher average power, enabling breakthrough equipment productivity by simply increasing scan speed.

## Applications

### Industry:

- > Ceramics micro-drilling
- > OLED Cutting UV and DUV
- > Metal large area texturing

### Science:

- > X-Ray Imaging
- > Accelerators

## Key Features

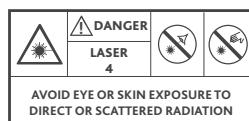
- > Real Pulse on Demand with FemtoTrig®
- > High Adaptability with FemtoBurst®
- > Higher Throughput with GHz Burst®
- > High Energy Burst up to 4.5mJ within a burst



# AXIS

## Specifications

|                                | AXIS 120                      |
|--------------------------------|-------------------------------|
| Power                          | 120 W                         |
| Energy                         | 500 $\mu$ J                   |
| Pulse Duration                 | < 500 fs                      |
| Adjustable pulse duration      | Up to 10 ps                   |
| Repetition Rate                | Single shot to 40 MHz         |
| Repetition Rate for max energy | 240 kHz                       |
| Ellipticity                    | < 13 %                        |
| Astigmatism                    | < 25 %                        |
| Wavelength                     | 1030 nm +/- 3 nm              |
| Spectrum Bandwidth             | < 3 nm                        |
| M2                             | < 1.2                         |
| Beam diameter                  | 3,25 mm                       |
| Pointing Stability             | < 20 $\mu$ rad / $^{\circ}$ C |
| p to p stability               | < 1% RMS                      |
| Power Stability (8hrs)         | < 0,5% RMS                    |
| Laser Head                     | 680 x 555 x 182 mm            |



AVOID EYE OR SKIN EXPOSURE TO  
DIRECT OR SCATTERED RADIATION

## OPTIONS

|             |  |
|-------------|--|
| Femtotrig®  | Energy level locked for a constant fluence & overlap when repetition rate is driven by an external device (galvo or stage) |
| Femtoburst® | Burst shaping  |
| GHz burst   | from 32 to more than 6,000 pulses (1.28 GHz)   |
| Harmonic    | SHG/THG monowave module or Harmonic Generator*   |

\*not compatible with GHz option



SHG / THG



Compress



Synclock



Harmonic Generator